

Title (en)

METAL COMPLEXES FOR GAS-PHASE THIN-FILM DEPOSITION

Title (de)

METALLKOMPLEXE FÜR GASPHASEN-DÜNNSCICHTABSCHIEDUNG

Title (fr)

COMPLEXES MÉTALLIQUES POUR DÉPÔT DE COUCHE MINCE EN PHASE GAZEUSE

Publication

EP 3947405 A1 20220209 (DE)

Application

EP 20713663 A 20200327

Priority

- EP 19165935 A 20190328
- EP 2020058865 W 20200327

Abstract (en)

[origin: WO2020193794A1] The invention relates to metal complexes of formula (I): $[M(L_1)_x(L_2)_y(\text{hydra})_z]_n$ formula (I) wherein: M = metal atom of an atomic number selected from the ranges a) to c): a) 12, 21 to 34, with the exception of 30, b) 39 to 52, with the exception of 48, c) 71 to 83, with the exception of 80, L1 = neutral or anionic ligand, with x = 0 or 1, L2 = neutral or anionic ligand, with y = 0 or 1, (hydra) = acetone dimethylhydrazone monoanion, with z = 1, 2 or 3, n = 1 or 2, and the total charge of the complex is 0.

IPC 8 full level

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CPC (source: EP KR US)

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Citation (search report)

See references of WO 2020193794A1

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DOCDB simple family (application)

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